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### (54) DISPLAY SUBSTRATE AND DISPLAY **APPARATUS**

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### ABSTRACT

A display substrate includes a substrate, a first conductive layer including a plurality of first signal lines, a first planarization layer and a plurality of anodes. An orthographic projection of at least one of the plurality of anodes on the substrate is non-overlapped with an orthographic projection of each first signal line on the substrate; and/or an orthographic projection of at least one of the plurality of anodes on the substrate is overlapped with an orthographic projection of one or more first signal lines on the substrate. In an anode and at least one first signal line whose orthographic projections on the substrate are overlapped, the at least one first signal line crosses a setting portion of the anode, so that by taking a center line of the anode in the first direction as an axis of symmetry, heights of the anode at symmetrical positions are substantially equal.

